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PATENT
ATTORNEY DOCKET: 46884-5428

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
)
Katsumi SHIBAYAMA) Confirmation No.: 4124
)
Application No.: 10/550,688) Group Art Unit: 2814
)
Filed: July 14, 2006) Examiner: Pham Long
)
For: PHOTODIODE ARRAY AND)
PRODUCTION METHOD THEREOF,)
AND RADIATION DETECTOR)

Commission for Patents
U.S. Patent and Trademark Office
Customer Window, Mail Stop Amendment
Alexandria, VA 22314

Sir:

RESPONSE TO RESTRICTION REQUIREMENT

In an Office Action dated March 9, 2007, the period for response to which extends through April 9, 2007, the Examiner required restriction/election under 35 U.S.C. §§ 121 and 372 between Group I, (claims 1-6 and 11-12) allegedly drawn to “a semiconductor device” or Group II (claims 7-10), allegedly drawn to “a semiconductor process”.

Applicant hereby elects Group I (claims 1-6 and 11-12) for examination.

Applicant respectfully requests formal examination of this application.

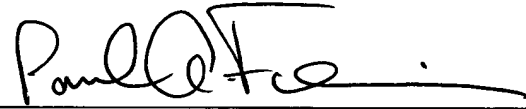
Applicant respectfully asserts that no additional fee is due in connection with the filing of this response. However, if there are any additional fees due in connection with the filing of this response, please charge those fees to Deposit Account No. 50-0573.

Respectfully submitted,

DRINKER, BIDDLE & REATH LLP

Dated: March 27, 2007

By:



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